

East 8 WPI DJPO

L Number	Hits	Search Text	DB	Time stamp
1	1625192	etch\$ or patern\$ or remov\$	JPO; DERWENT	2004/10/15 10:36
2	2012874	(bond\$ pad) or (contact pad)	JPO; DERWENT	2004/10/15 10:37
3	307877	resist or photoresist or mask or photomask	JPO; DERWENT	2004/10/15 10:38
4	17602	passivat\$	JPO; DERWENT	2004/10/15 10:38
5	641458	adhes\$	JPO; DERWENT	2004/10/15 10:38
6	2225243	adhes\$ layer	JPO; DERWENT	2004/10/15 10:38
7	17348	(etch\$ or patern\$ or remov\$) and ((bond\$ pad) or (contact pad)) and (resist or photoresist or mask or photomask) and (passivat\$ or (adhes\$ layer))	JPO; DERWENT	2004/10/15 10:39
8	36628	(bond\$ with pad) or (contact with pad)	JPO; DERWENT	2004/10/15 10:39
9	149036	adhes\$ with layer	JPO; DERWENT	2004/10/15 10:40
10	8016	(etch\$ or patern\$ or remov\$) with (adhes\$ with layer)	JPO; DERWENT	2004/10/15 10:40
11	7928	passivat\$ with layer	JPO; DERWENT	2004/10/15 10:40
12	1765	(etch\$ or patern\$ or remov\$) with (passivat\$ with layer)	JPO; DERWENT	2004/10/15 10:40
13	635	((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad))	JPO; DERWENT	2004/10/15 10:41
14	635	(etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))	JPO; DERWENT	2004/10/15 10:41
15	20586	bond\$ with pad	JPO; DERWENT	2004/10/15 10:41
16	73	((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) and (bond\$ with pad)	JPO; DERWENT	2004/10/15 11:15
17	562	((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)	JPO; DERWENT	2004/10/15 11:15
18	57	((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad) and solder\$	JPO; DERWENT	2004/10/15 11:15

East 8 WPID, JPO

L Number	Hits	Search Text	DB	Time stamp
1	1625192	etch\$ or patern\$ or remov\$	JPO; DERWENT	2004/10/15 10:36
2	2012874	(bond\$ pad) or (contact pad)	JPO; DERWENT	2004/10/15 10:37
3	307877	resist or photoresist or mask or photomask	JPO; DERWENT	2004/10/15 10:38
4	17602	passivat\$	JPO; DERWENT	2004/10/15 10:38
5	641458	adhes\$	JPO; DERWENT	2004/10/15 10:38
6	2225243	adhes\$ layer	JPO; DERWENT	2004/10/15 10:38
7	17348	(etch\$ or patern\$ or remov\$) and ((bond\$ pad) or (contact pad)) and (resist or photoresist or mask or photomask) and (passivat\$ or (adhes\$ layer))	JPO; DERWENT	2004/10/15 10:39
8	36628	(bond\$ with pad) or (contact with pad)	JPO; DERWENT	2004/10/15 10:39
9	149036	adhes\$ with layer	JPO; DERWENT	2004/10/15 10:40
10	8016	(etch\$ or patern\$ or remov\$) with (adhes\$ with layer)	JPO; DERWENT	2004/10/15 10:40
11	7928	passivat\$ with layer	JPO; DERWENT	2004/10/15 10:40
12	1765	(etch\$ or patern\$ or remov\$) with (passivat\$ with layer)	JPO; DERWENT	2004/10/15 10:40
13	635	((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad))	JPO; DERWENT	2004/10/15 10:41
14	635	(etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))	JPO; DERWENT	2004/10/15 10:41
15	20586	bond\$ with pad	JPO; DERWENT	2004/10/15 10:41
16	73	((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) and (bond\$ with pad)	JPO; DERWENT	2004/10/15 11:15
17	562	((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)	JPO; DERWENT	2004/10/15 11:15
18	57	((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad) and solder\$	JPO; DERWENT	2004/10/15 11:25
19	505	((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad) and solder\$)	JPO; DERWENT	2004/10/15 11:26

20	33	(((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) and ("438" or "216")	JPO; DERWENT	2004/10/15 11:33
21	472	(((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) and ("438" or "216")	JPO; DERWENT	2004/10/15 11:33
22	8	(((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) and ("438" or "216")) and ("156" or "437" or "257")	JPO; DERWENT	2004/10/15 11:35

23	464	((((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) not (((((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) and ("438" or "216")))) not ((((((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) not ((((((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) not (((etch\$ or patern\$ or remov\$) and (((etch\$ or patern\$ or remov\$) with (adhes\$ with layer)) or ((etch\$ or patern\$ or remov\$) with (passivat\$ with layer)))) and (resist or photoresist or mask or photomask) and ((bond\$ pad) or (contact pad)))) not (bond\$ with pad)) and solder\$)) and ("438" or "216")))) and ("156" or "437" or "257"))	JPO; DERWENT	2004/10/15 11:35
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